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10/06/00

Class	Subclass

ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.	PATENT DATE
ACGH SCANNED Q.A. 16	

APPLICATION NO. 09/679514	CONT/PRIOR	CLASS 438	SUBCLASS 759	ART UNIT 2812	EXAMINER J. J. J.
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APPLICANTS

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TITLE

Method to improve passivation openings by reflow of photoresist to eliminate flux residue.

PTO-2040
12/89

ISSUING CLASSIFICATION												
ORIGINAL				CROSS REFERENCE(S)								
CLASS		SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)							
INTERNATIONAL CLASSIFICATION												

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<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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	<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____ _____ _____			ISSUE FEE	
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<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Primary Examiner) (Date)			ISSUE BATCH NUMBER	
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